

JAN 05 2004

Application No.: 10/017,805

OFFICIAL

Docket No.: JCLA7245

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of :

Shun-Li Lin

Serial No. : 10/017,805

Filed : October 31, 2001

For : Photoresist With Adjustable
Polarized Light Reaction And
Photolithography Process Using The
Photoresist

Examiner : THORNTON, YVETTE C

Art Unit : 1752

Docket No. : JCLA7245

No fee is believed to be due. However, the Commissioner is authorized to charge any fees required in connection with the filing of this paper to account No. 50-0710 (Order No. JCLA7245).

RESPONSE TO NON-COMPLIANT AMENDMENTAMENDMENT AND RESPONSE TO OFFICE ACTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response Notice of Non-Compliant Amendment dated 12/29/2003, Applicant resubmitted the amendment and response previously filed on 12/10/2003. No new matter has been added.

The Office Action mailed September 11, 2003 (Paper No. 6), has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.

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